Preparation of Cr-Doped TiO$_2$ Thin Film of P-type Conduction for Gas Sensor Application

A. Ruiz, A. Cornet, G. Sakai, K. Shimanoe, J. R. Morante, and N. Yamazoe

Unlike the undoped TiO$_2$ film (n-type), the Cr (8.7 atom%)-doped one showed p-type character and responded well to dilute NO$_2$ in air at 500 °C by a sharp decrease in electrical resistance.